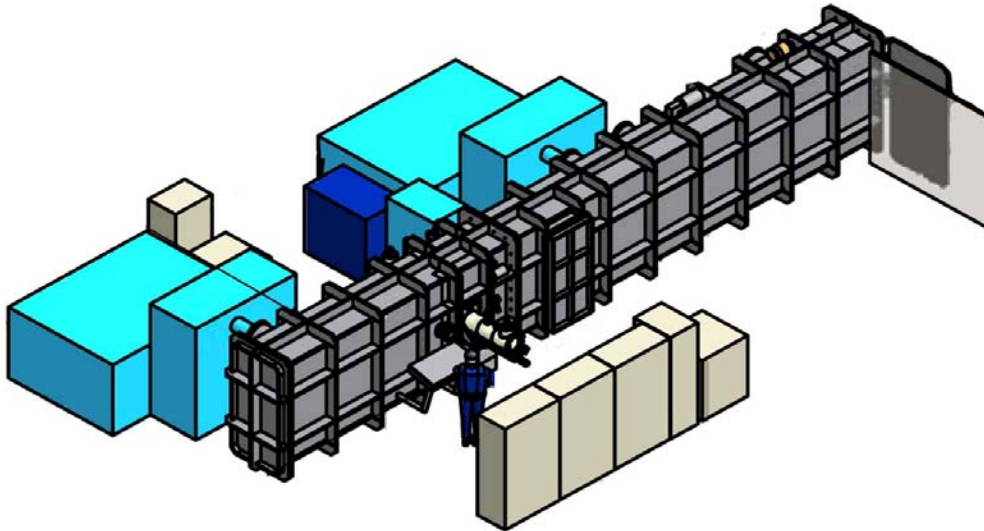


Universal Chamber EB Machine type K200



Application

The single chamber design allows for EB processing of a wide range of work pieces. When operating the machine, the process steps, such as workpiece change, chamber evacuation, electron beam processing, chamber ventilation and the next workpiece change, are performed in succession and within the time intervals that are technologically necessary.

Using the pro-beam EB generator a wide range of welding, brazing and surface applications can be processed, including multi-beam technology, multi-focus technology and multi-process technology.

Technical data

Chamber

Chamber volume	20 m ³
Installation area	135 m ²
Installation height	2.500 mm
Working space length	8.500 mm
Working space width	700 mm
Working space height	170 mm

Run-out platform

Length	8.000 mm
Width	800 mm
Height	250 mm

X-Y coordinate table

Travel x (NC) 3.500 mm
speed range 1 - 100 mm/s

Electron beam generator

pro-beam EB generator 80 .. 150 kV

Vacuum

Partial vacuum $\leq 2 \times 10^{-2}$ mbar
Evacuation time ≤ 10 min

Media

Supply voltage 3 x 400V, $\pm 10\%$, 50Hz; TN-S System
Pressurized air 6 bar $\pm 10\%$
Cooling water according to VGB-R 455 P

Acceptance criteria

acceptance test accoring DIN 14744, including X-ray test, sample processing and acceptance certificate

Accessories

Flat palete
Manipulation devices

Options:

Generator sliding device
seperate PLC control panel
2-hand control
Polycold

Additional features and special design are available on request.